Supporting Information

for

Ordered arrays of nanoporous gold nanoparticles

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Additional SEM images
**Figure S1:** SEM images of the pre-patterned substrate showing the periodic array of pyramidal pits: (a) plan view, and (b) at tilt of 25°.

**Figure S2:** SEM image of the Au–Ag alloy nanoparticles dewetted from 10 nm Au/20 nm Ag bilayers on the pre-patterned substrate via annealing at 700 °C in Ar for 15 min.
Figure S3: SEM images (at tilt of 25°) of arrays of nanoporous gold nanoparticles induced via annealing at 700 °C in Ar for 15 min and then dealloying from: (a) 10 nm Au/25 nm Ag bilayers, (b) 10 nm Au/30 nm Ag bilayers, and (c) 15 nm Au/25 nm Ag bilayers.